

# **A proposal for an unusually stiff and moderately ductile hard coating material: $\text{Mo}_2\text{BC}$**

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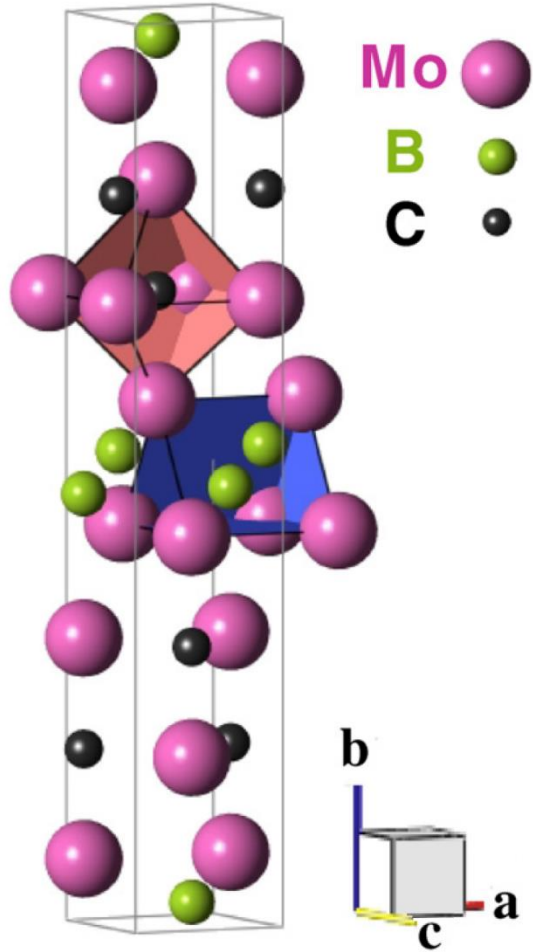
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# Introduction

- Protection of tools – thin films
- Most thin films – hard but brittle
- Combination of hardness and moderate ductility to prevent formation and spreading of cracks
- Nanolaminate  $\text{Mo}_2\text{BC}$
- Prepared by magnetron sputtering

# Mo<sub>2</sub>BC coatings



Material	B (GPa)	B/G
TiN	295	1,39
Ti <sub>0,25</sub> Al <sub>0,75</sub> N	178	1,44
c-BN	376	0,98
Mo <sub>2</sub> BC	324	1,72

- Combination of great hardness and moderate ductility
- Stiff Mo-B and Mo-C layers with metallic interlayer bonding
- B – bulk modulus
- G – shear modulus
- $B/G > 1,75$  ductile materials
- Mo<sub>2</sub>BC thin films were synthesized using DC magnetron sputtering on Al<sub>2</sub>O<sub>3</sub> at a substrate temperature of ~900 °C

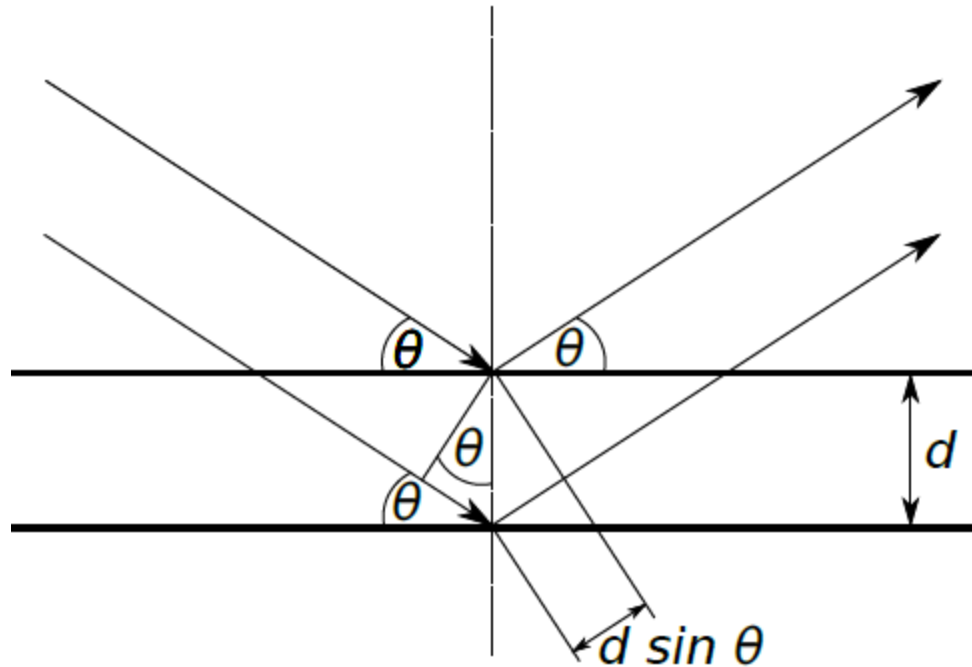
# Used characterization methods

- X-ray diffraction
- Scanning electron microscopy
- Electron recoil detection analysis

# X-ray diffraction (XRD)

- Information about the crystal structure
- Uses the scattering of photons on the atoms of the lattice
- The superposition of the scattered waves from individual atoms leads to classical reflection of light
- The incident rays are reflected from the atomic planes and interfere with each other
- Constructive interference occurs, when the Bragg condition is met

# X-ray diffraction (XRD)

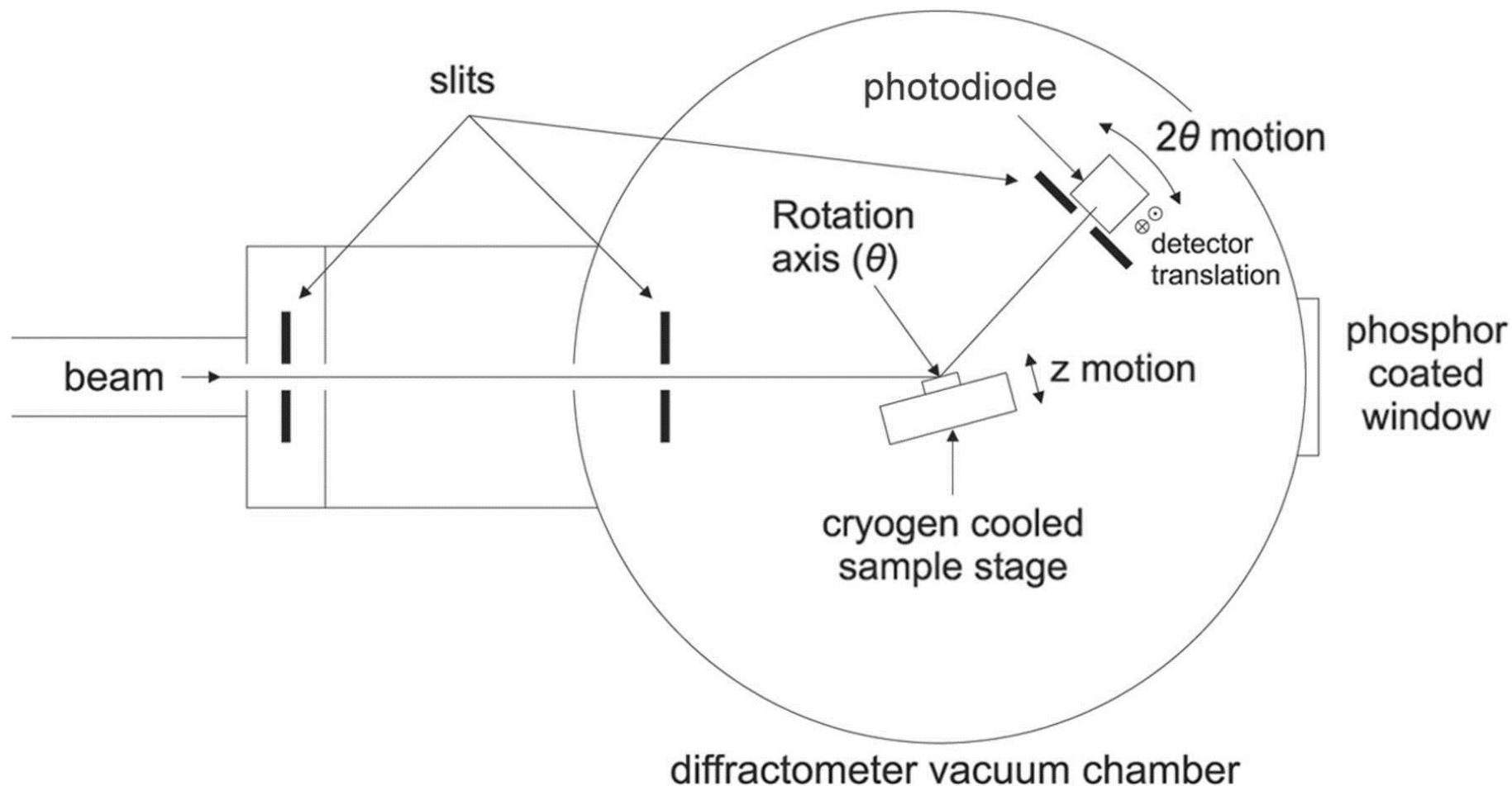


- The Bragg equation:

$$2d \sin \theta = n\lambda$$

- $\lambda$  is the wavelength of the incident light,  
 $d$  is the distance between atomic planes,  
 $n$  is an integer and  
 $\theta$  is the angle of incidence.

# X-ray diffraction (XRD)



# X-ray diffraction (XRD)

- Three methods of measuring:
  - Debye-Scherrer – monochromatic light and polycrystalline material
  - Laue – polychromatic light and monocrystalline material
  - Monochromatic light and monocrystalline material
- The combination of polychromatic light and polycrystalline material creates too many diffractions



# X-ray diffraction (XRD)

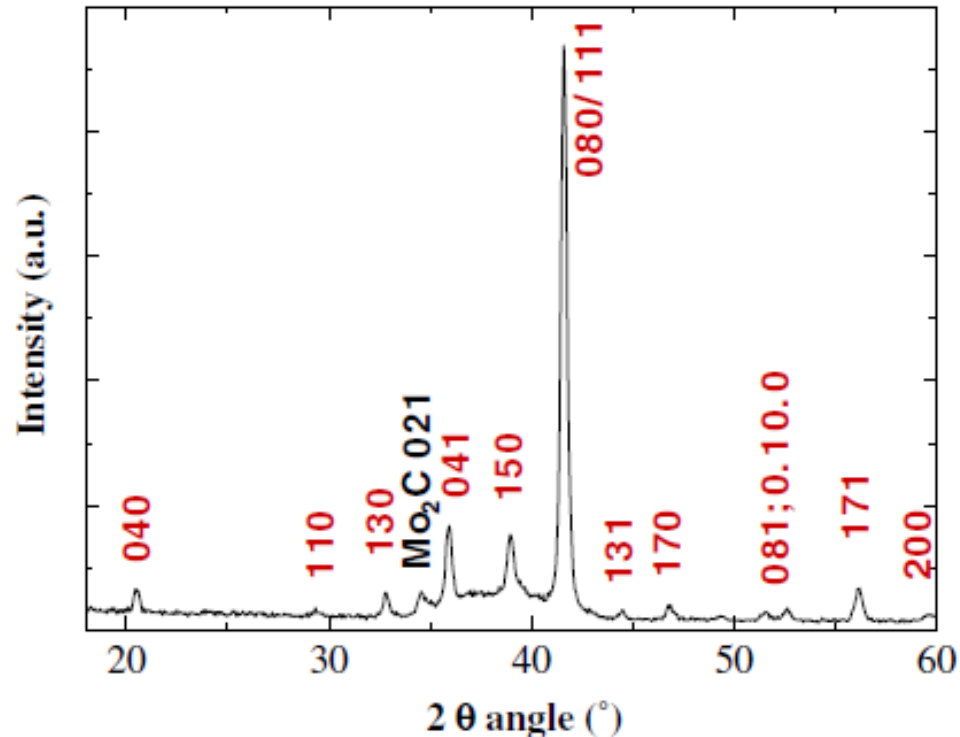


Figure 5. X-ray diffractogram of a Mo<sub>2</sub>BC thin film deposited at ~900 °C on Al<sub>2</sub>O<sub>3</sub>(0001) substrate.

- The sample consists predominantly of Mo<sub>2</sub>BC
- There is a minor contribution detected, stemming from Mo<sub>2</sub>C
- Good agreement between the measured peak positions and the reference values
- The relative intensities of the diffractogram do not match due to the sample being textured

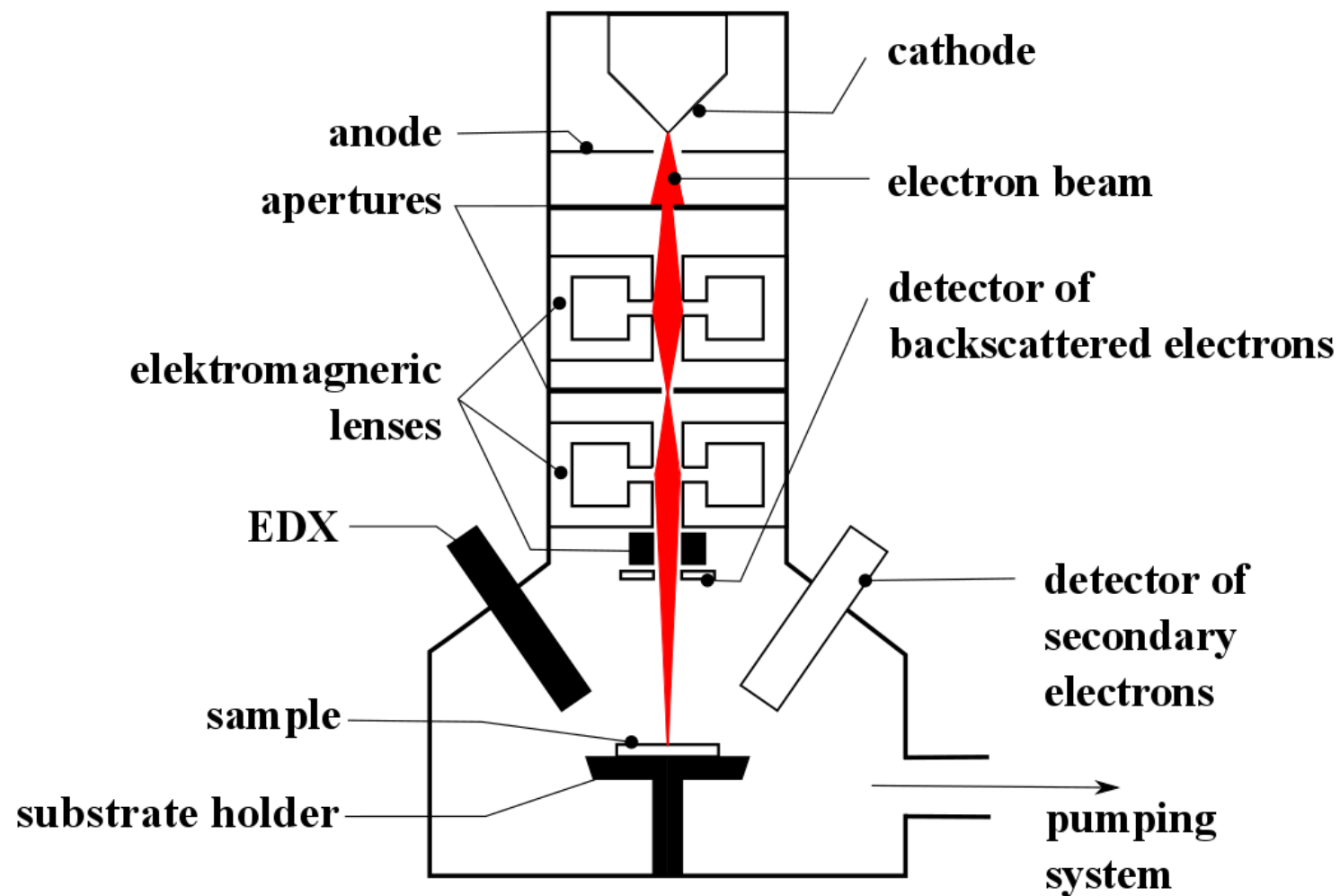
# Scanning electron microscopy (SEM)

- Used for imaging of surfaces
- Focused beam of accelerated electrons
- The beam is focused and directed by electromagnetic lenses and scans the surface
- High vacuum is necessary to prevent collisions of electrons with gas particles
- Possibility to use with EDX or WDX to determine composition

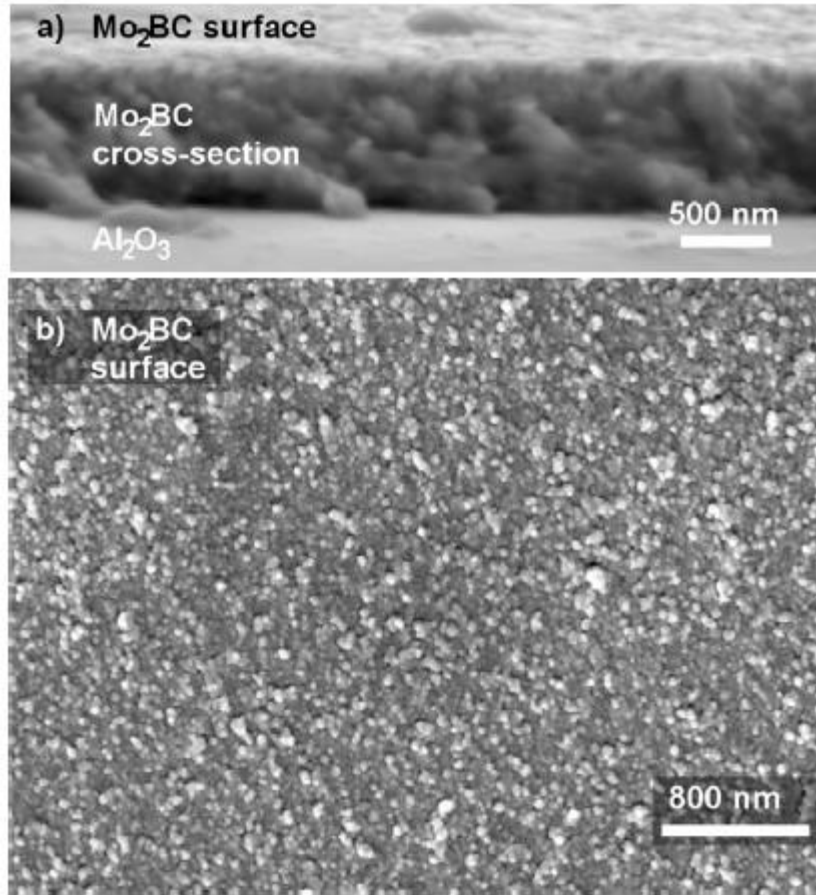
# Scanning electron microscopy (SEM)

- Two basic kinds of signal:
- Backscattered electrons
  - Electrons with high energy reflected from the surface
  - Greater penetration depth but worse spatial resolution
  - Number of reflected electrons depends on the atomic number of the particle – greater mass – more reflected electrons – brighter spot
- Secondary electrons
  - Electrons emitted from the surface due to inelastic scattering
  - Because of their low energy, only electrons created at the surface leave the sample
  - Mostly information about topography – electrons are emitted mostly from sharp edges

# Scanning electron microscopy (SEM)

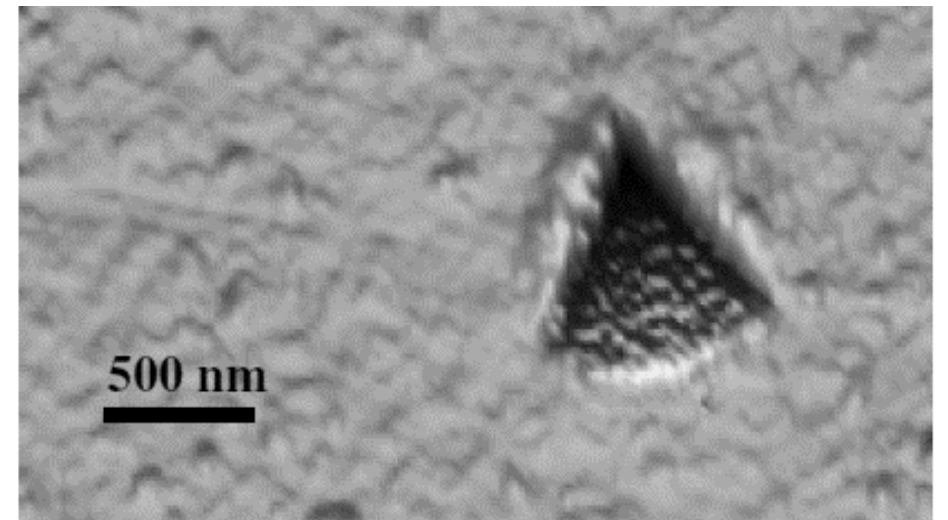


# Scanning electron microscopy (SEM)



**Figure 6.** SEM image of (a) cross-section and (b) surface of a Mo<sub>2</sub>BC thin film grown at  $\sim 900^\circ\text{C}$  on Al<sub>2</sub>O<sub>3</sub>(0001).

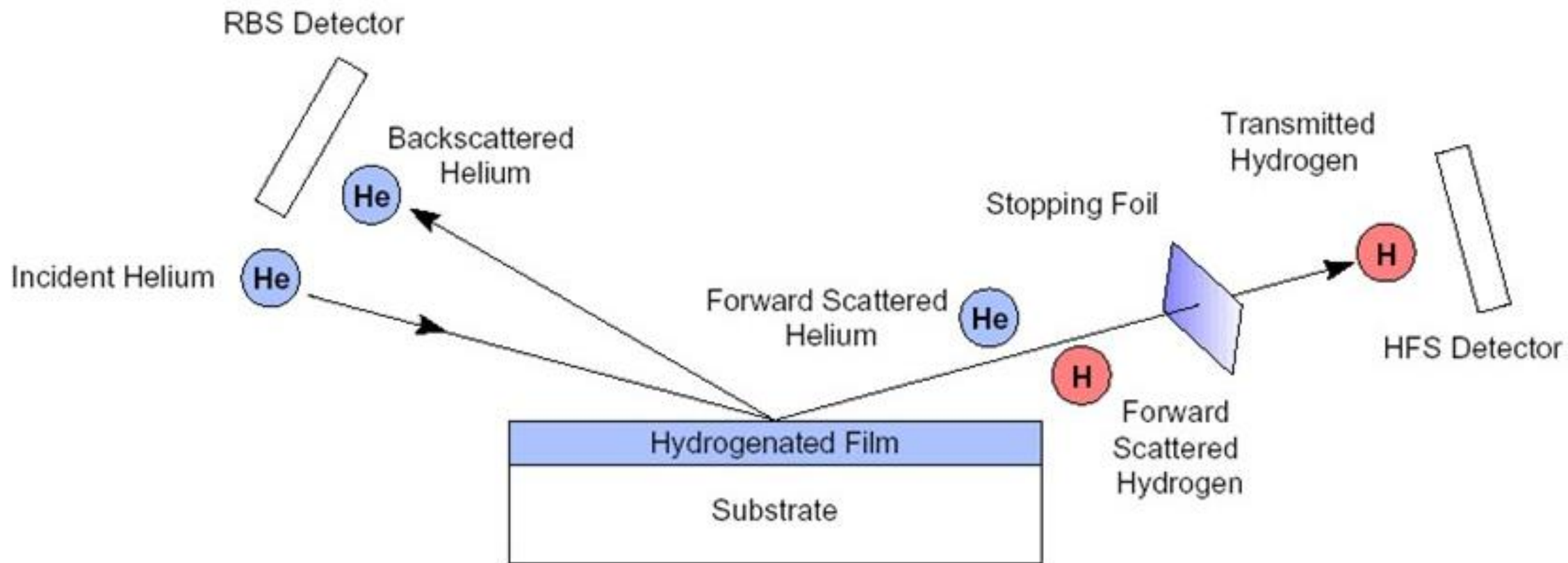
- No formation of pores or cavities
- Surface features with a diameter well below 100 nm
- No crack formation observed around the indent



# Energy recoil detection analysis (ERDA)

- Detection of light elements in a heavy matrix
- Analysis of forward scattered ions or atoms
- A single collision
- Particles can be identified by their kinetic energy
- Analysis of particles: TOF, thin foil

# Energy recoil detection analysis (ERDA)



# Energy recoil detection analysis (ERDA)

- The film consists of 49 at% Mo, 27 at% B and 24 at% C
- The chemical formula  $\text{Mo}_2\text{B}_{1.1}\text{C}_1$ , which is very close to the nominal stoichiometry of  $\text{Mo}_2\text{BC}$ .
- O and H were not detected in the film.
- The variation of B from stoichiometric  $\text{Mo}_2\text{BC}$  composition is within the expected measurement error.



# Conclusion

- $\text{Mo}_2\text{BC}$  thin films were synthesized using DC magnetron sputtering on  $\text{Al}_2\text{O}_3$  at a substrate temperature of  $\sim 900$  °C.
- XRD measurements and ERDA confirmed that the grown film is almost phase pure and of near-stoichiometric composition
- No formation of cracks was observed implying moderate ductility
- Deformation experiments carried out with nanoindentation confirmed the high stiffness of  $\text{Mo}_2\text{BC}$

# Thank you for your attention!

J. Emmerlich, D.Music, M. Braun, P. Fayek, F. Munnik, J.M. Schneider, J. Phys. D: Appl. Phys. 42 (2009) 185406

Peter E.J. Flewitt, R.K. Wild: *Physical Methods for Materials Characterisation*, Series in Materials Science and Engineering

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<http://journals.iucr.org/s/issues/2005/04/00/kv5008/kv5008fig1.html>